

Application News

Spectrophotometric Analysis

No.A428

Measurements of Band Gap in Compound Semiconductors - Band Gap Determination from Diffuse Reflectance Spectra -

The determination of band gap in materials is important to obtain the basic solid state physics. Band gap indicates the difference in energy between the top of the valence band filled with electrons and the bottom of the conduction band devoid of electrons. The bandgap is related to the electric conductivity of the materials. There is generally no band gap in metals, but the band gap value in insulators is known to be large, and that in semiconductors is typically

intermediate between these two.

Here we introduce band gap determination from Tauc plots obtained from diffuse reflectance spectra of samples consisting of compound semiconductor materials, which in this case were provided by the Wada Laboratory, Faculty of Science and Technology, Ryukoku University. The experiments were also conducted with the cooperation of the Wada Laboratory, Ryukoku University.

■ Samples, Instrument and Attachment Used for Measurement

Three kinds of powder samples (CuInSe_2 , $\text{CuIn}_{0.5}\text{Ga}_{0.5}\text{Se}_2$, and CuGaSe_2), which consisted of copper (Cu), indium (In), selenium (Se) and gallium (Ga) were used as the samples. These compounds are currently receiving attention as compound semiconductors in solar battery. The samples were prepared for measurement by piling a small amount on a layer of barium sulfate powder, after which the sample powder was spread into a thin uniform layer using a glass rod. The sample preparation and final sample state as prepared for measurement are shown in Fig. 1 and Fig. 2.

The ISR-3100 integrating sphere attachment was mounted in the UV-3600 UV-VIS-NIR spectrophotometer as shown in Fig. 3, and diffuse reflectance spectra of the prepared samples were recorded. Barium sulfate was used as a standard. The obtained UV-VIS-NIR spectra are shown in Fig. 4, and the measurement conditions are shown in Table 1. It is clear that there are differences in the position of the absorption edge (position at which reflectance decreases). This difference indicates the difference of the band gap between samples.



Fig. 1 Sample Placed on BaSO_4 Powder

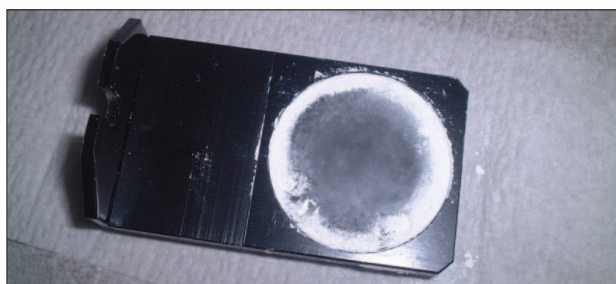


Fig. 2 Sample Spread on BaSO_4 Powder

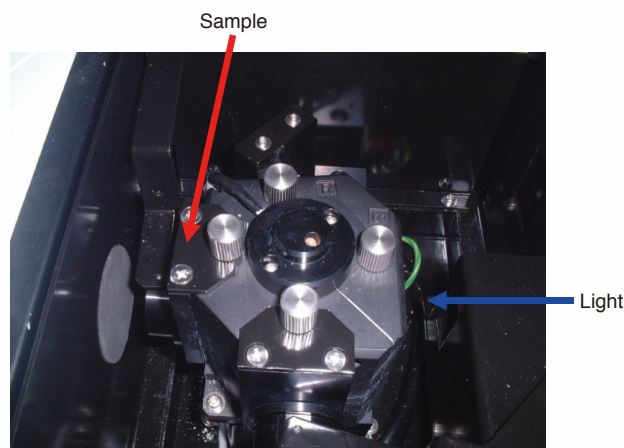


Fig. 3 Sample Set in ISR-3100 Integrating Sphere

Table 1 Analytical Conditions

Measurement Wavelength Range	: 600 nm to 1800 nm
Scan Speed	: Medium
Sampling Pitch	: 1.0 nm
Photometric Value	: Reflectance
Slit Width	: (20) nm
Grating Switching Wavelength	: 720 nm
Detector Switching Wavelength	: 830 nm

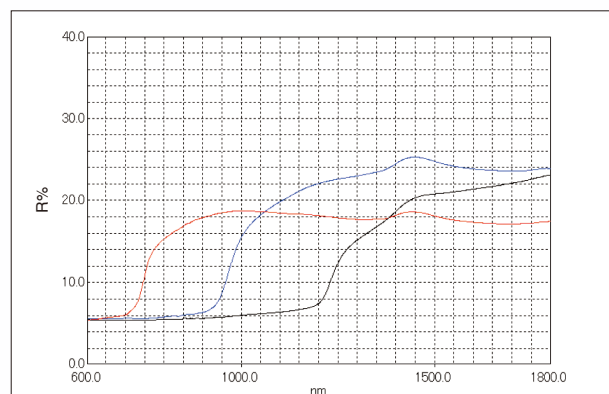


Fig. 4 Diffuse Reflectance Spectra
(Red: CuGaSe_2 , Blue: $\text{CuIn}_{0.5}\text{Ga}_{0.5}\text{Se}_2$, Black: CuInSe_2)

■ Calculation of Band Gap Using Tauc Plot

The Tauc plot is a method that is widely used for the determination of band gap. Shown next is the procedure for determining the band gap from a diffuse reflectance spectrum using the Tauc plot.

■ Process for Obtaining Band Gap Using Tauc Plot

(1) The following relational expression proposed by Tauc, Davis, and Mott is used.

$$(h\nu)^{1/n} = A(h\nu - E_g) \quad (1)$$

Where:

h: Planck's constant, ν : frequency of vibration, α : absorption coefficient,

E_g : band gap, A: proportional constant

The value of the exponent n denotes the nature of the sample transition.

For direct allowed transition n = 1/2

For direct forbidden transition n = 3/2

For indirect allowed transition n = 2

For indirect forbidden transition n = 3

Since the direct allowed sample transition is used in this experiment, n = 1/2 is used for these samples.

(2) The acquired diffuse reflectance spectrum is converted to Kubelka-Munk function. Thus, the vertical axis is converted to quantity $F(R_\infty)$, which is proportional to the absorption coefficient. The α in the Tauc equation is substituted with $F(R_\infty)$. Thus, in the actual experiment, the relational expression becomes:

$$(h\nu F(R_\infty))^2 = A(h\nu - E_g) \quad (2)$$

(3) Using the Kubelka-Munk function, the $(h\nu F(R_\infty))^2$ was plotted against the $h\nu$. The curve that plots the value of $(h\nu - (h\nu F(R_\infty))^2)$ on the horizontal axis $h\nu$ and vertical axis $(h\nu F(R_\infty))^2$ is drawn.

Here, the unit for $h\nu$ is eV (electron volts), and its relationship to the wavelength λ (nm) becomes $h\nu = 1239.7/\lambda$.

(4) A line is drawn tangent to the point of inflection on the curve of step (3), and the $h\nu$ value at the point of intersection of the tangent line and the horizontal axis is the band gap E_g value.

Note: The point of inflection is found by taking the first derivative of the curve. The point at which the value of the first derivative coefficient begins to decrease after increasing is the point of inflection.

The curve that plots the value of $(h\nu - (h\nu F(R_\infty))^2)$ and the respective tangent, based on the procedures of steps (3) and (4), are shown for each sample in Fig. 5 to Fig. 7. The value associated with the point of intersection of the line tangent to the plotted curve inflection point with the horizontal axis ($h\nu$ axis) becomes the band gap E_g value. The E_g values obtained using Shimadzu's UVProbe software with commercially available spreadsheet software are shown in Table 2. The band gap values are shown using the typical eV unit, but these values are also presented in nm in parentheses for comparison with the actual data of the diffuse reflectance spectra. It is clear that the values presented in nm correspond well with the absorption edge wavelengths of the diffuse reflectance spectra in Fig. 4.

In this measurement, the band gap was determined for three types of compound semiconductor materials (CuInSe_2 , $\text{CuIn}_{0.5}\text{Ga}_{0.5}\text{Se}_2$, CuGaSe_2). These are often used as the functional material in solar batteries based on the compound semiconductors, however, as demonstrated here, these 3 types possess different band gap values. Application of the Tauc relational expression, as shown in this example, allows determination of the band gap in powder samples using the diffuse reflectance spectrum.

Acknowledgment

We wish to express our deep gratitude for the considerable support and cooperation and for the guidance and samples provided by Dr. Takahiro Wada and Dr. Seiji Yamazoe of the Dept. of Materials Chemistry, Faculty of Science and Technology, Ryukoku University.

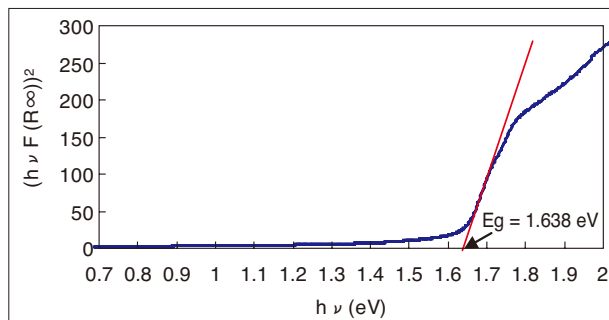


Fig. 5 $h\nu - (h\nu F(R_\infty))^2$ Curve of CuGaSe_2

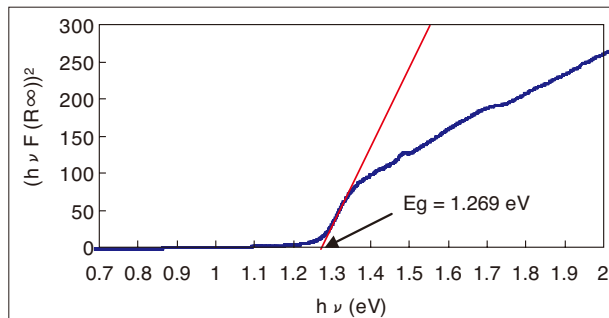


Fig. 6 $h\nu - (h\nu F(R_\infty))^2$ Curve of $\text{CuIn}_{0.5}\text{Ga}_{0.5}\text{Se}_2$

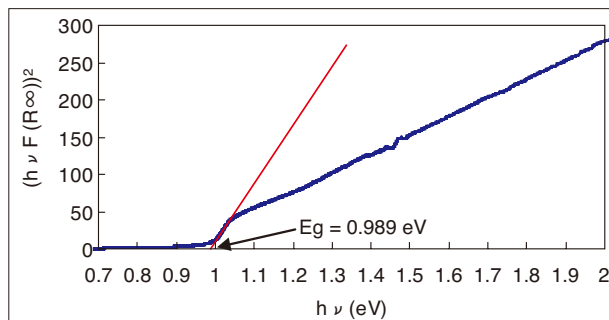


Fig. 7 $h\nu - (h\nu F(R_\infty))^2$ Curve of CuInSe_2

Table 2 Band Gap E_g of CuGaSe_2 , $\text{CuIn}_{0.5}\text{Ga}_{0.5}\text{Se}_2$ and CuInSe_2

Sample Name	Band Gap E_g
CuGaSe_2	1.64 eV (757 nm)
$\text{CuIn}_{0.5}\text{Ga}_{0.5}\text{Se}_2$	1.27 eV (977 nm)
CuInSe_2	0.99 eV (1253 nm)

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- 3) E. A. Davis and N. F. Mott, Philos. Mag., 22 903 (1970).



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